

AMENDMENTS TO THE CLAIMS

The listing of the claims will replace the previous version, and the listing of the claims:

LISTING OF THE CLAIMS

1. (currently amended) An antireflection film comprising:  
an organic,  
a hard-coating layer laminated on the organic film,  
a high refractive index layer laminated on the hard-coating layer and having a refractive index in a range of 1.65 to 1.85, said high refractive index layer being formed of metal oxide particles of ITO with electrical conductivity and TiO<sub>2</sub> with high refractive index, a volume percentage of the TiO<sub>2</sub> particles to a total volume of the TiO<sub>2</sub> and ITO particles in the high refractive index layer being 1 to 60%, and at least one synthetic resin selected from the group consisting of styrene resin, epoxy resin and acrylic resin, a volume percentage of the metal oxide particles to a total volume of the metal oxide particles and the at least one synthetic resin being 20% or more, and  
a low refractive index layer laminated on the high refractive index layer and having a refractive index in a range of 1.35 to 1.55, said low refractive index layer being formed of acrylic resin containing with fluorine or silicone resin and further including particles of fluorine resin in an amount of 10 to 40% therein by weight to improve reduction of refractive index of the antireflection film, resistance to scuffing and slipperiness of the antireflection film, wherein said antireflection film has a surface resistance of 5 x 10<sup>12</sup>Ω/□ or less.

2-13. (cancelled)

14. (currently amended) An antireflection film as claimed in claim 7 1, wherein said hard coating layer includes electrically conductive metal oxide particles to have antistatic properties.

15. (previously presented) An antireflection film as claimed in claim 14, wherein said volume percentage of the metal oxide particles to the total volume of the metal oxide particles and the synthetic resin is 40 to 60%.

16. (new) An antireflection film as claimed in claim 14, wherein said high refractive index layer has a thickness between 75 and 90 nm, and said low refractive index layer has a thickness between 85 and 110 nm.

17. (new) An antireflection film as claimed in claim 16, wherein said refractive index of the low refractive index layer is 1.45 or less to provide a minimum surface reflectance of 0.5% or less for the antireflection film.